Homework #2 - EE 482 due 1/18/11 (Tuesday due to MLK holiday)

- 1. Sketch the Fermi-Dirac distribution and appropriate forms of the Maxwell-Boltzmann approximation versus energy on a common set of axes. How far must the energy be above the Fermi level at 300K for the appropriate M-B approximation to result in an error of less than 3% in the occupation probability? How far below? Repeat for probability of being empty $(1-p_{occ})$.
- 2. The outer occupied energy band in a crystal with N atoms per unit volume is described by

$$E = E_0 + \frac{\hbar^2 (k - k_0)^2}{2m^*}$$

and the band contains one electron per atom.

- (a) Is this material an insulator, a metal or a semiconductor? Explain.
- (b) Give an expression for $E_f E_0$ at 0K in terms of m^* ? (Hint the Fermi-Dirac distribution has a particularly simple form at 0K).
- 3. Find the equilibrium electron and hole concentrations and the location of the Fermi level for **ger-manium** at 27°C if the germanium contains the following concentrations of shallow dopant atoms:
 - (a) $5 \times 10^{16} \,\mathrm{cm}^{-3}$ phosphorus atoms.
 - (b) $10^{18} \,\mathrm{cm}^{-3}$ boron atoms and $5 \times 10^{17} \,\mathrm{cm}^{-3}$ phosphorus atoms.

Calculate the resistivity for these two samples.

- 4. (a) Express the Fermi level relative to the intrinsic Fermi level as a function of doping, temperature and intrinsic carrier concentration in a n^- (lightly-doped n-type) semiconductor if n_i cannot be neglected relative to $N_d - N_a$.
 - (b) If a silicon wafer is doped with $N_d = 10^{18} \text{ cm}^{-3}$ of arsenic atoms, calculate the position of the Fermi level E_f and carrier concentrations at 750°C. Note: You can get n_i vs. T from plot in the notes. Alternatively, to use equation, N_c and N_v vary with temperature so use N_c , N_v proportional to $T^{\frac{3}{2}}$ and account for the change in band-gap with temperature.
- 5. A silicon wafer is doped with 10^{17} cm⁻³ of manganese, which has a donor level 0.53eV below the conduction band. ($E_g = 1.12$ eV)
 - (a) Determine the Fermi level relative to the conduction band and the carrier concentrations in this sample at 300K.
 - (b) Repeat for a sample with 10^{17} cm⁻³ of manganese and 2×10^{17} cm⁻³ of arsenic.
 - (c) Repeat for a sample with 10^{17}cm^{-3} of manganese and $2 \times 10^{17} \text{cm}^{-3}$ of boron.